



# Manufacturing solutions for today and tomorrow: Cutting-edge production equipment for TOPCon and beyond

#### Speaker:

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Director of Technology - International Business Unit

#### **COMPANY PROFILE**

Multiple Breakthroughs in Solar Innovation:

- Pioneer of TOPCon for mass production
- Vanguard of TOPCon+
- Innovator of BackContact (BC) with almost100% market share
- New deposition platform for perovskite-based tandem





## **LAPLACE Experience**

## PROJECT EXPERIENCE



- > >470 GW of TOPCon/P-IBC/N-IBC/PERC equipment delivered (CNY ~ 15 BN, USD ~ 2.1 BN)
- > >20GW outside of China from Southeast Asia and USA
- Biggest project: 30GW
- 1,000+ people in support: extensive experience in manufacturing of TOPCon & BC technology with cuttingedge performance and IP



## CUSTOMER RECOGNITION



























## **LAPLACE International**



#### **International Customers**

- USA
- Southeast Aisa

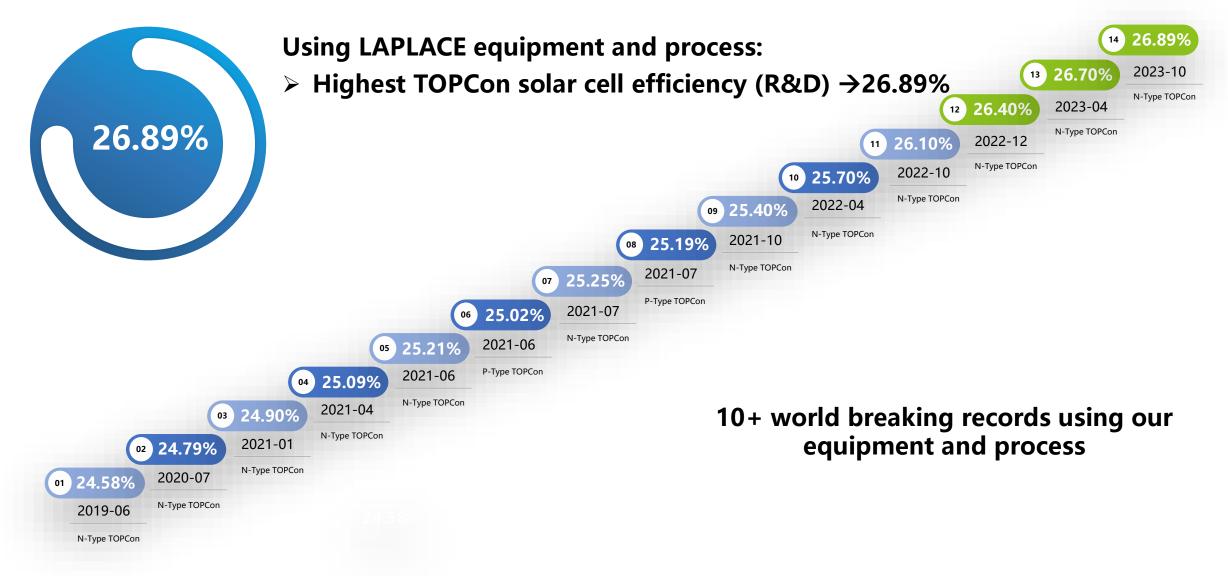
#### **Laplace international**

- Hong Kong (China)
- Southeast Asia
- Europe
- USA

- Shenzhen (Headquarter)
- Wuxi
- Haining
- Taizhou
- Xi' an
- Guangzhou



#### **Development of Cutting-edge Technology at LAPLACE**





#### **LAPLACE innovations for TOPCon**



Million € Cumulative R&D expenditure

02

01

#### Pioneering transition from BBr<sub>3</sub> to BCl<sub>3</sub>

> 70% cost reduction

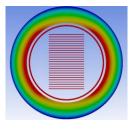
#### **Double-loading** (back-to-back wafers)

- Diffusion, Oxidation and LPCVD
- Doubled throughput without need of change in process flow
- Highest throughput for LPCVD, much lower CoO in comparison with **PECVD**

#### In-House Heating elements

03

- Improved thermal uniformity, shorter processing time
- Longer quartz parts lifetime





#### **Quartz tube** inside coating

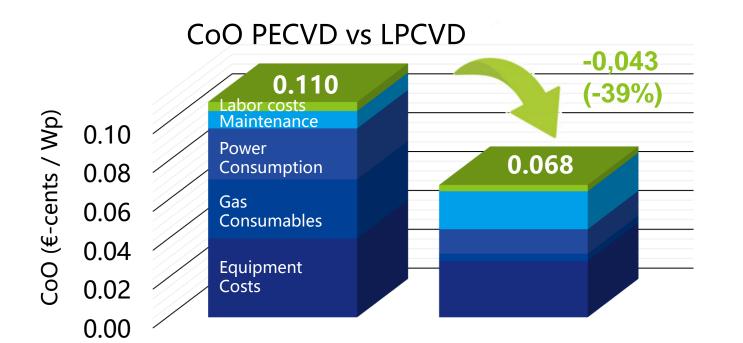
- Pre-coating by nano crystallization technology
- Tube lifetime increase to over 6-9 months





### **LAPLACE LPCVD route**

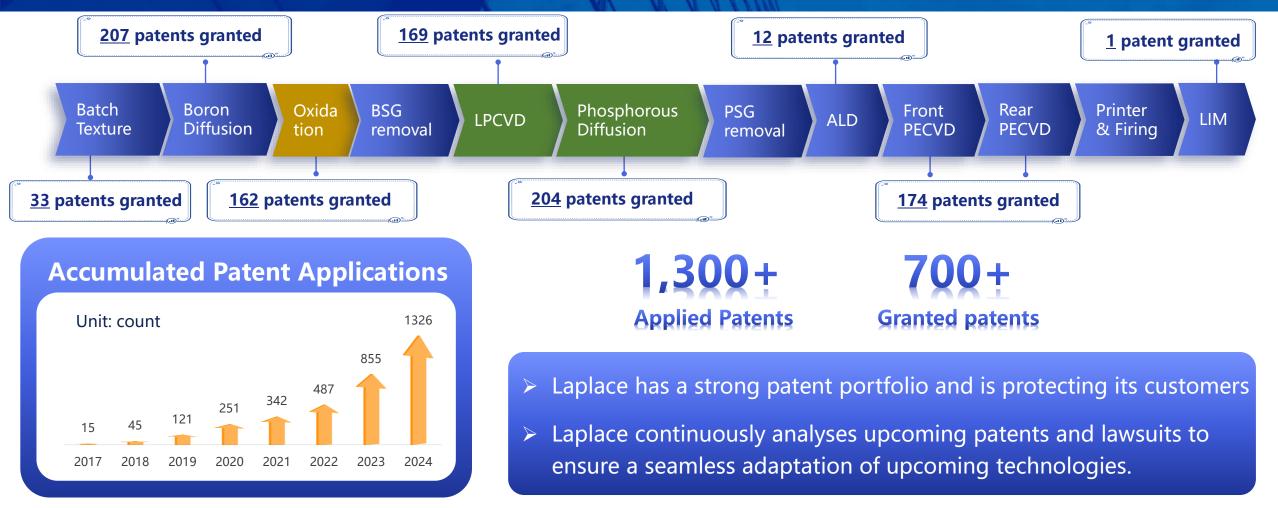
- > Laplace has improved the tool efficiency: For M10 wafers, besides double loading, GEN 4 Laplace tools have 2400 wafers/tube while GEN 5 has 2880 wafers/tube
- **Quartz tube inside coating:** Pre-coating by nano crystallization technology increased tube lifetime to over 6-9 months



GEN5 tools (double loading) combined with increased tube lifetime have improved significantly the CoO of LPCVD with today a ~40% lower CoO than PECVD.



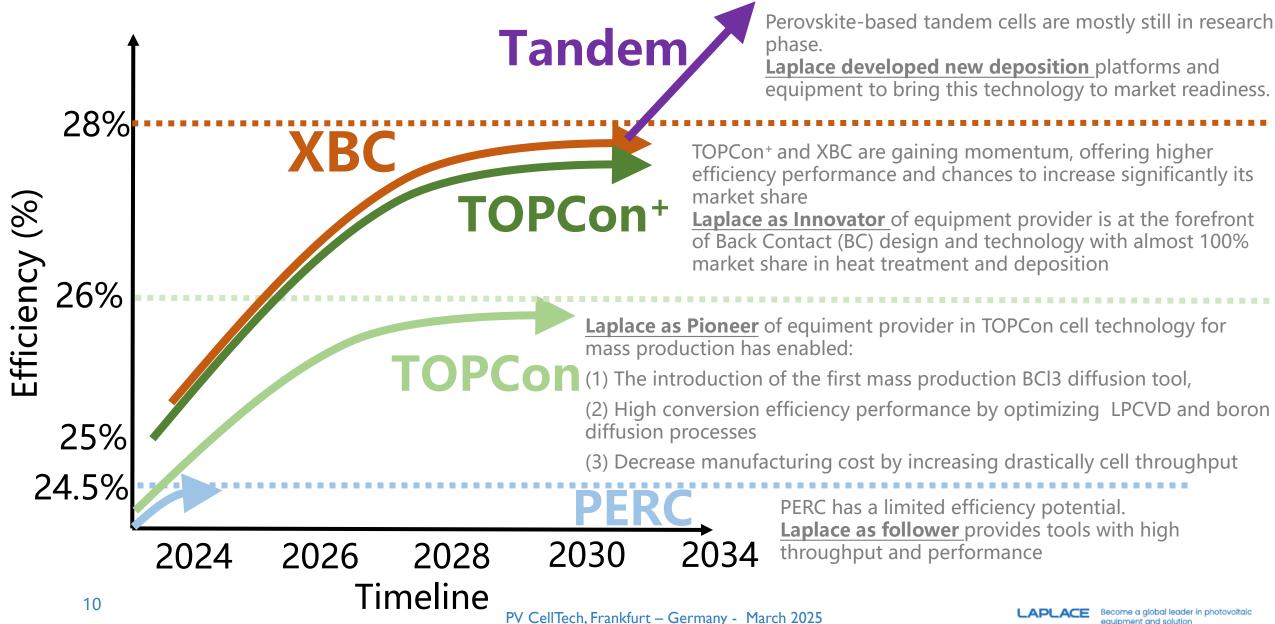
### **LAPLACE Equipment Patent Portfolio**



Laplace proprietary LPCVD with ex-situ doping technology allows customers to sell to USA and Europe



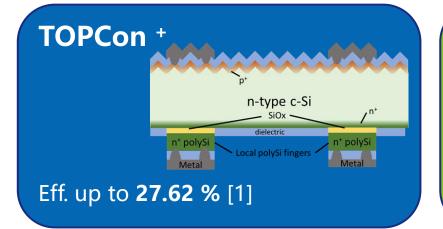
## **LAPLACE Technology Roadmap of PV Cell**





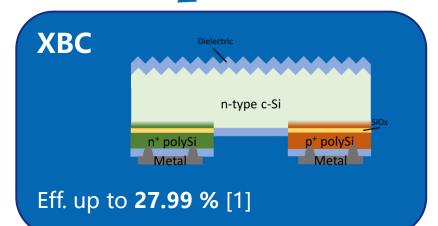
## **LAPLACE Technology Roadmap**

#### **TOPCon**



#### **Similar requirements**

- Stable, uniform, thermal SiOx
- Lasers gain importance



#### **Tandem**

Perovskite-based tandem cells are mostly still in research phase. Laplace has developed new platforms and equipment that are currently in pilot lines.

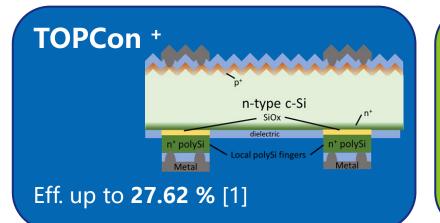


## **LAPLACE Technology Roadmap**

Today's presentation

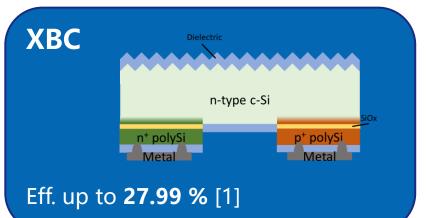
#### **TOPCon**

TaiyangNews
December 2024 (Youtube)



#### Similar requirements

- Stable, uniform, thermal SiOx
- Lasers gain importance



#### **Tandem**

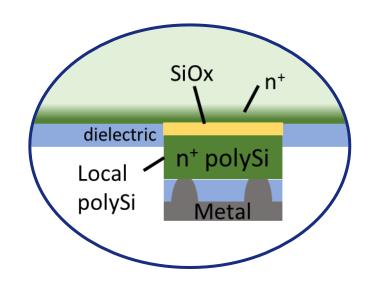
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### LAPLACE's leading role for TOPCon plus and XBC equipments

Laplace is strongly supporting our customers to achieve their goals in mastering TOPCon plus and XBC

Most important demand for all TOPCon plus and XBC cells: Stable, reproducible, uniform, thermal SiOx layer



For localized polySi, either as polySi fingers or XBC design, lasers are the most cost-efficient way for patterning

Laplace developed advanced laser technology for all critical steps in TOPCon plus and XBC manufacturing

Our system is **fully compatible** for the polySi implementation in TOPCon<sup>+</sup> and XBC cells, with equipment already delivered and operating successfully.



## **LAPLACE** next generation solar cells in the Industry

Laplace has delivered successfully equipment for the critical process steps with almost 100% market share for TOPCon+ and BC cells

	TOPCon	TOPCon+	Back Contact
Capacity Installed: Expected total in 2025:	≥ 700 GW <sup>1</sup> ≥ 750 GW <sup>1</sup>	50 GW¹ ≥ 100 GW¹	52.5 GW¹ ≥ 105 GW¹
Cells: Average warehouse efficiency	~ 25.0 %¹	~ 25.2 % <sup>1</sup>	~25.6 % <sup>1</sup>
Modules: Current G12R commercial efficiency: Next commercial efficiency: (announced for 2025)	22.8 % (615 W) <sup>2</sup>	23.5 % (635 W) <sup>3</sup> 24.8 % (670 W) <sup>5</sup>	24.2 % (655 W) <sup>4</sup> 24.8 % (670 W) <sup>6</sup>
Bifaciality:	80 %	85 %	70 %
Manufacturing Complexity weighted score: (1:easy, TOPCon: 6, difficult: 10)	6 (moderate)	7 (moderate)	10 (hard)
Required manpower: (TOPCon as reference 100%):	100 %	103 %	120%

<sup>[1]</sup> Company financial and Public Investor Meeting Minutes

[5] December 2024, Taiyang News Conference

[6] taivangnews.info/technology/longi-breaks-global-module-mass-production-efficiency-record



<sup>[2]</sup> https://taiyangnews.info/topmodules/top-solar-modules-listing-november-2024

<sup>[3]</sup> https://www.jinkosolar.com/en/site/dwparametern

<sup>[4]</sup> https://taiyangnews.info/technology/aiko-solar-module-efficiency



### **LAPLACE Equipment Portfolio for TOPCon Cell Line**

Wet etch

B Diff.

Oxidation

Etch & Clean

LPCVD

P Diff.

Etch & Clean

ALD

Front PECVD

Rear PECVD

Metalli zation Test Sort

#### **Heat treatment**

**Solid State diffusion and Oxidation** 

#### **Boron Diffusion**

- Pioneering BCl3
- 5TH GENERATION
- > 900 machines delivered
- Rank first by market share
  - **Oxidation & Annealing**
- 5TH GENERATION
- > 700 machines delivered coating film.
  - **Phosphorous Diffusion**
- 5<sup>TH</sup> GENERATION
- > 300 machines delivered
- Larger production capacity, and can reduce costs

## **Deposition**

#### **LPCVD**

- 5<sup>TH</sup> GENERATION
- > 1,100 machines delivered
- Rank first by market share

#### ALD

- 2<sup>ND</sup> GENERATION
- Double-layer sealing ensures the uniformity of the coating film.

#### **PECVD**

- 5<sup>TH</sup> GENERATION
- > 500 machines delivered
- Larger production capacity, and can reduce costs

#### **Automation**

Loading, transfer, up to full automation for entire cell line

> 1,700 machines
 delivered

























Front **PECVD** 

Rear Metalli **PECVD** zation

Test Sort

#### **Atomic Edge Passivation Deposition Complete Solution (EPD)**



Cut wafers in half and passivate to edges to recover

the losses



Non-destructive laser is used to separate the wafer in

two pieces. Half cells are stacked to a coin-stack and

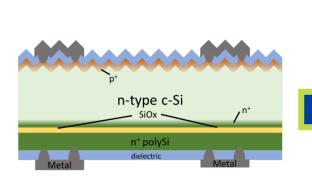
a passivation layer is deposited on the edges.

**Dimensions:** 

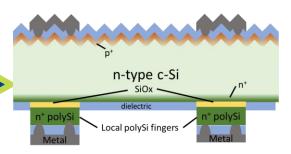
19,04 x 4,60 x 3,70 m

Throughput:

10000 pcs/h (M10)



	Warehouse Cell Efficiency	G12R Module Power	G12R Module Efficiency
TOPCON	25.2 %	635	23.5 %
EPD	+ 0.3 %	+ 6 W	+ 0.2 %
			_
<b>TOPCon Plus</b>	25.5 %	641 W	23.7 %

























Front **PECVD** 



Metalli zation

Test Sort



#### **Poly Thickness Removal via Laser Ablation**

**G12R** 

**Function:** 

bifaciaity factor

**Mechanism: Dimensions:** 

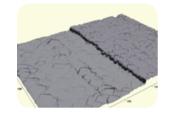
**Throughput:** 

Reduce parasitic absorption, increase conversion efficiency and

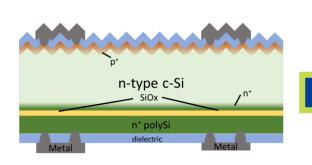
Remove poly-silicon locally

5,56 x 4,00 x 2,80 m 9000 pcs/h (M10)

**G12R** 

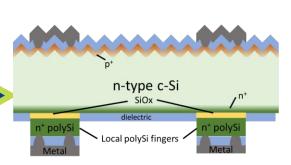


3D morphology of etching edge



	Cell Efficiency	Module Power	Module Efficiency
TOPCON	25.2 %	635	23.5 %
EPD	+ 0.3 %	+ 6 W	+ 0.2 %
PolSi fingers	+ 0.15 %	+ 3 W	+ 0.1 %
<b>TOPCon Plus</b>	25.65 %	644 W	23.8 %

Warehouse









Oxidation

Etch & Clean

LPCVD

P Diff.

Laser

Etch & Clean

Front **PECVD** 

Rear **PECVD**  Metalli zation

Test Sort



Additional ALD tools are required to passivate front and rear side



#### **Poly Thickness Removal via Laser Ablation**

**G12R** 

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bifaciaity factor

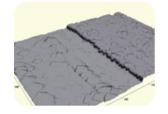
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**Dimensions: Throughput:**  Reduce parasitic absorption, increase conversion efficiency and

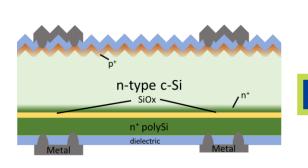
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**G12R** 

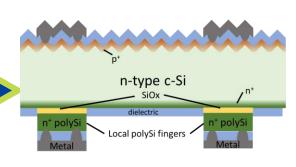


3D morphology of etching edge



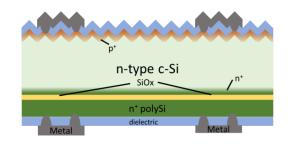
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Warehouse



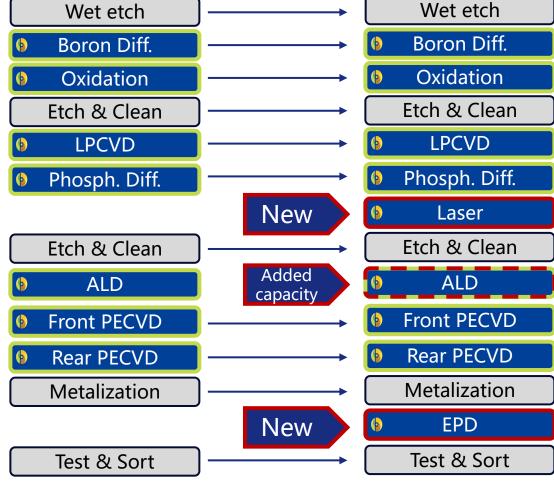


## **TOPCon**

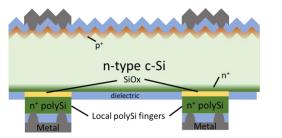


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#### Efficiency + 0.45 % Module gain + 9 W



## TOPCon+





## **Summary**

#### Innovation for TOPCon:

#### Experience:

Pioneers of TOPCon for mass production with

> 470 GW equipment delivered

#### **Double-loading for LPCVD**

→ Highest throughput in the market: 40% lower CoO compared to PECVD deposition tools

#### **Proprietary coated quartz tube**

→ Double and potentially triple the lifetime of quartz tubes

## Leading equipment for TOPCon+ and XBC:

- Laplace toolset is fully compatible for TOPCon+ and XBC integration.
- Strong support for our customers to achieve their goals in successfully achieve mass production
- New equipment:

  New laser tools for TOPCon+ and BC, facilitating the process flow with local openings



## THANKS!

推动新能源技术创新,造福人类 Enable Renewable Energy Innovation for a Sustainable Future